



# Fully Automatic Polisher **DFP8140/8160**

# **Chemical- and slurry-free stress relief**



Relieve wafer stress without slurry, chemicals or water. The DFP8140/8160 effectively removes the grinding induced damage layer by utilizing a dry polishing process. This process greatly reduces wafer breakage and warpage while improving die strength. The result is superior product yield, even for today's ultra-thin wafers (<100 microns).

#### **In-Line System**

The DFP8140/8160's design allows it to be integrated with Disco grinders for an in-line wafer thinning solution that grinds, dry polishes, and transports wafers safely and securely (in-line system requires optional accessories).







No. E892 - ISO 14001



LCD touch screen

#### **Environmentally Friendly Process**

Unlike chemical etching or CMP, the dry polishing process does not require costly waste treatment and x disposal. Dry polishing with the DFP8140/8160 is environmentally friendly while maintaining a lower cost of ownership than other stress relief processes.

#### **Easy Operation**

The DFP8140/8160 utilizes the same operator interface and machine layout as the Disco Fully Automatic Grinder (DFG8540/8560). This ensures reduced training time for operators familiar with Disco equipment. For those new to the 8000 Series, the touch-screen graphical user interface with real-time process data makes both operation and maintenance tasks easy to learn and accomplish.

Utilities Power supply

Power consumption

**Fully Automatic Polisher** 

**DFP**8140/8160



Handy panel

DFP8140/8160 Specifications

			DFP8140	DFP8160
Wafer Diameter		-	Max. Ø8"(04*~08*)	Max.ø300mm(@8"~@12")
Processing Method		-	Anomalous In-feed grinding with wafer rotation	
Spindle	Туре	-	Air bearing with high frequency motor	
	Number of axes	-		1
	Output	kW	4.8	7.5
	Revolution speed	min <sup>-1</sup>	1,000~4,000	1,000~3,000
	Z-axis vertical stroke	mm	100(with zero point)	72(with zero point)
	Z-axis vertical grinding feed speed	mm/s	0.0001~0.08	
	Z-axis vertical fast feed speed	mm/s	50	
	Min. Z-axis vertical movement	μm	0.1	
	Min. Z-axis vertical movement resolution	μm	0.1	
Wafer Chuck Table	Chuck table type	-	Porous chuck table	
	Chuck method	-	Vacuum	
	Number of revolutions	min <sup>-1</sup>	0~300	
	Number of chuck tables	-	1	
	Chuck table cleaning	-	Backflushing of water and compressed air is combined with oilstone cleaning and brush cleaning	
	Wafer cleaning	-	Washing using an atomizing nozzle	
	Internal load sensor	-	Thin force sensor	
	Spark Out (chuck table revolutions setting)	-	0~999	
	Y-axis processing stroke	mm	420	510
	Y-axis max.speed	mm/s	0.5~200	
	Y-axis min. resolution	mm	0.002	
Dry Polishing Wheel		mm	ø300	ø450
Wafer Han	dling Section / Wafer Cleaning Section	ion		
	Cassette storage quantity	-	2	
	Cassette flow	-	Same flow and open flow	
	Spinner unit	-	Water washing by atomizing nozzle and drying	
Vacuum Unit	Discharge speed	m³/h	29/36 50/60 Hz	
	Achievable pressure	kPa	<ul> <li>-90 (water supply temperature 15 °C, water supply flow rate 1 L/min)</li> </ul>	
	Electric motor	kW	1.5	
	Water flow rate			
	When supplied water temperature is greater than 22 $^{\circ}\mathrm{C}$	L/min	3	
	When supplied water temperature is less than 22 °C	L/min	1	
Polishing Residue Collector	System	-	Wet cyclone system	
	Cylinder volume	m³/min	4.0	
	Motor	kW	1.0	
	Water used	L/min	4.0	
Processir	ng Accuracy			
	Variation in removal amount	μm	±1 or less (when rem	oving 2 µm in average)



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DISCO CORPORATION

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When processing kW 4.6 (for reference) 6.5 (for reference 2.8 (for reference) During warm-up kW 5.0 (for refere Max. power kVA 12 19 Air pressure Main body MPa 0.5~0.8 Polishing residue collector MPa 0.3~0.5 Air flow rate L/min(ANR 550 or higher Main body Polishing residue collector L/min(ANR) 50 or higher Water pressure Grinding and cleaning MPa 0.3~0.4 0.2~0.3 Cooling MPa Vacuum pump MPa 0.052~0.49 Polishing residue collector MPa 0.2~0.3 Water flow rate Grinding and cleaning L/min 20 or higher Coolina L/min 4 or higher Vacuum pump When supplied water temperature is greater than 22 °C L/min 3 When supplied water temperature is less than 22 °C L/min 1 Polishing residue collector L/mir 4 or higher Exhaust duct capacity 4 or higher 1,200 x 2,670 x 1,800 1,400 x 3,322 x 1,800 Machine dimensions (WxDxH) mm 1.900 Machine weight 2,400 ka

A vacuum unit and polishing residue collector are installed as standard.

#### Environmental conditions

-Use clean, oil-free air at a dew point of -15 °C or less. (Use a residual oil: 0.1 ppm Wt/Wt. Filtration rating: 0.01  $\mu m/99.5$  % or more).

•Keep room temperature fluctuations within ±1 °C of the set value. (Set value should be between 20~25 °C). • Keep self-grinding water and cleaning water 2 °C above room temperature (fluctuations within 1 °C over one hour).

• Keep spindle cooling water temperature between 20~25 °C (fluctuations within 2 °C over an hour)

• The machines should be used in an environment, free from external vibration. Do not install machine near a ventilation opening, heat generation equipment or oil mist generating parts. This machine uses water.

In case of water leakage, please install the machine on the floor with sufficient waterproofing and drainage treatments.

\* All the pressures are described using a gauge pressure.

\* The above specifications may change due to technical modifications. Please confirm when placing your order \* For further information please contact your local sales representatives.

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200 ~ 240 V V AC ±10 %, 3-phase (50/60 Hz)

## **DFP8160 DFP8140**